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1,4-Bis[4-(dimethylsilyl)phenyl]benzene

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Key indicators: single-crystal X-ray study; T = 173 K; mean σ (C–C) = 0.004 Å; R factor = 0.071; wR factor = 0.133; data-to-parameter ratio = 19.3.

The complete molecule of the title compound, $C_{22}H_{26}Si_2$, is generated by a crystallographic centre of symmetry. The central benzene ring makes a dihedral angle of 26.7 (4)° with the 4-(dimethylsilyl)phenyl ring. There are weak $C-H\cdots\pi$ interactions in the crystal structure.

Related literature

For applications of *p*-terphenyl derivatives as laser dyes, see: Craig *et al.* (1992), as light-emitting materials, see: Spiliopoulos *et al.* (2002) and as liquid crystalline materials, see: Yam *et al.* (1993). For a description of the Cambridge Structural Database, see: Allen (2002); Although *p*-terphenyls containing silyl groups have been reported (Feng *et al.*, 2007), their crystal structures have not yet been determined.



b = 7.7263 (15) Å

c = 9.1285 (18) Å

V = 1018.5 (3) Å³

 $\beta = 107.52 \ (3)^{\circ}$

Experimental

Crystal data

$C_{22}H_{26}Si_2$
$M_r = 346.61$
Monoclinic, $P2_1/c$
a = 15.143 (3) Å

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Z = 2
Mo K\alpha radiation
\mu = 0.18 \text{ mm}^{-1}
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Data collection

Rigaku Saturn724+ CCD
diffractometer
Absorption correction: multi-scan
(CrystalClear; Rigaku, 2008)
$T_{\min} = 0.966, T_{\max} = 0.986$

Refinement

 $R[F^2 > 2\sigma(F^2)] = 0.071$ H atoms treated by a mixture of
independent and constrained
refinementS = 1.21refinement2218 reflections $\Delta \rho_{max} = 0.31 \text{ e Å}^{-3}$ 115 parameters $\Delta \rho_{min} = -0.22 \text{ e Å}^{-3}$

Table 1

Hydrogen-bond geometry (Å, °).

Cg1 is the centroid of the C1-C6 ring.

$D - H \cdot \cdot \cdot A$	D-H	$H \cdot \cdot \cdot A$	$D \cdots A$	$D - \mathbf{H} \cdot \cdot \cdot A$
$\begin{array}{c} \hline C8-H8b\cdots Cg1^{i} \\ C10-H10a\cdots Cg1^{ii} \end{array}$	0.98 0.95	2.86 2.98	3.826 (3) 3.788 (3)	171 143
Symmetry codes: (i) x, -	$-y + \frac{1}{2}, z - \frac{1}{2};$ (ii	i) $x, -y + \frac{3}{2}, z +$	$+\frac{1}{2}$.	

Data collection: *CrystalClear* (Rigaku, 2008); cell refinement: *CrystalClear*; data reduction: *CrystalClear*; program(s) used to solve structure: *SHELXS97* (Sheldrick, 2008); program(s) used to refine structure: *SHELXL97* (Sheldrick, 2008); molecular graphics: *ORTEPIII* (Burnett & Johnson, 1996); software used to prepare material for publication: *SHELXL97*.

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Supplementary data and figures for this paper are available from the IUCr electronic archives (Reference: FB2186).

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organic compounds

 $0.20 \times 0.18 \times 0.08 \text{ mm}$

7661 measured reflections 2218 independent reflections

1937 reflections with $I > 2\sigma(I)$

T = 173 K

 $R_{\rm int} = 0.043$

supplementary materials

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1,4-Bis[4-(dimethylsilyl)phenyl]benzene

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Comment

p-Terphenyl derivatives have attracted considerable attention due to their extensive applications. Among others, they may be used as laser dyes (Craig *et al.*, 1992), light-emitting materials (Spiliopoulos *et al.*, 2002), liquid crystalline materials (Yam *et al.*, 1993). Although *p*-terphenyls containing silyl groups have been reported (Feng *et al.*, 2007), their crystal structures have not been given yet.

The title molecules are situated on the crystallographic centres of symmetry (Fig. 1). Two dimethylsilylphenyl-rings are linked to the central benzene ring in its 1,4 (*para*) positions. The rings are not coplanar; the dihedral angle between the dimethylsilylphenyl-ring and the central benzene ring equals to 26.7 (4)°. There are C-H… π -electron ring interactions in the structure (Tab. 1).

The distance Si1-H1 (1.39 (3)Å) is in a fair accordance to the structures with the R-factor < 0.06 that have been retrieved from the Cambridge Crystallographic Database (version 5.31 from December 2009 with updates up to February 2010). (Allen, 2002). The average retrieved distance is 1.419 (14) Å for 21 observations. [The searched structures contained Si-fragment as it is in the title structure: 2 C atoms in sp³ state, 1 in sp² state, 1 H. The structures with extensively deviated distances (ROLDIF, ROLDIF01, POZNEX, CODVOH, YOYBOD) have been suppressed.]

Experimental

The reaction scheme is shown in Fig. 2. A solution of *n*-BuLi in hexane (1.6 M, 0.88 ml) was added dropwise to a solution of 1,4-bis(4-iodophenyl)benzene (192 mg, 0.40 mmol) in anhydrous tetrahydrofuran (THF) (80 ml) at -78 °C. After the solution having been stirred for 1 h, dimethylchlorosilane (152 mg, 1.60 mmol), also cooled to the same temperature, was added by syringe. The mixture was allowed to warm to room temperature and it was stirred overnight. After it had been quenched with saturated NaHCO₃ solution, the mixture was extracted with Et₂O. The organic layer was washed with brine, dried over anhydrous MgSO₄, filtered, and concentrated under reduced pressure. The mixture was recrystallized from ethanol to give 92 mg of the title product in 67% yield. The crystals were colourless needles with the average length of about 3 mm.

Refinement

All the hydrogens were discernible in the difference electron density maps. Nevertheless, all the hydrogens except the hydrogen attached to Si that was refined freely, were constrained by the riding-hydrogen formalism with $U_{iso}(H)=1.2U_{eq}(C_{aryl})$ or $U_{iso}(H)=1.5U_{eq}(C_{methyl})$. The C-H distances were constrained to 0.95 and 0.98 Å for the aryl and the methyl hydrogens, respectively.

Figures



Fig. 1. The title molecule, showing 50% probability displacement ellipsoids and the atomnumbering scheme. The atoms without labels are related to the labelled ones by -x, -y+1, -z+2.

Fig. 2. Reaction scheme for the synthesis of 1,4-bis(4-dimethylsilylphenyl)benzene

1,4-Bis[4-(dimethylsilyl)phenyl]benzene

$C_{22}H_{26}Si_2$	F(000) = 372
$M_r = 346.61$	$D_{\rm x} = 1.130 {\rm ~Mg~m}^{-3}$
Monoclinic, $P2_1/c$	Mo <i>K</i> α radiation, $\lambda = 0.71073$ Å
Hall symbol: -P 2ybc	Cell parameters from 347 reflections
a = 15.143 (3) Å	$\theta = 2.2 - 27.5^{\circ}$
<i>b</i> = 7.7263 (15) Å	$\mu = 0.18 \text{ mm}^{-1}$
c = 9.1285 (18) Å	T = 173 K
$\beta = 107.52 \ (3)^{\circ}$	Plate, colorless
V = 1018.5 (3) Å ³	$0.20\times0.18\times0.08\ mm$
Z = 2	

Data collection

Rigaku Saturn724+ CCD diffractometer	2218 independent reflections
Radiation source: fine-focus sealed tube	1937 reflections with $I > 2\sigma(I)$
graphite	$R_{\rm int} = 0.043$
ω scans at fixed $\chi = 45^{\circ}$	$\theta_{\text{max}} = 27.0^{\circ}, \theta_{\text{min}} = 2.8^{\circ}$
Absorption correction: multi-scan (CrystalClear; Rigaku, 2008)	$h = -19 \rightarrow 19$
$T_{\min} = 0.966, \ T_{\max} = 0.986$	$k = -9 \rightarrow 9$
7661 measured reflections	$l = -7 \rightarrow 11$

Refinement

Primary atom site location: structure-invariant direct methods
Secondary atom site location: difference Fourier map
Hydrogen site location: difference Fourier map
H atoms treated by a mixture of independent and constrained refinement
$w = 1/[\sigma^2(F_o^2) + (0.0276P)^2 + 0.8805P]$ where $P = (F_o^2 + 2F_c^2)/3$
$(\Delta/\sigma)_{\rm max} < 0.001$
$\Delta \rho_{max} = 0.31 \text{ e} \text{ Å}^{-3}$
$\Delta \rho_{min} = -0.22 \text{ e} \text{ Å}^{-3}$

46 constraints

Special details

Geometry. All esds (except the esd in the dihedral angle between two l.s. planes) are estimated using the full covariance matrix. The cell esds are taken into account individually in the estimation of esds in distances, angles and torsion angles; correlations between esds in cell parameters are only used when they are defined by crystal symmetry. An approximate (isotropic) treatment of cell esds is used for estimating esds involving l.s. planes.

Refinement. Refinement of F^2 against ALL reflections. The weighted *R*-factor wR and goodness of fit *S* are based on F^2 , conventional *R*-factors *R* are based on *F*, with *F* set to zero for negative F^2 . The threshold expression of $F^2 > \sigma(F^2)$ is used only for calculating *R*-factors(gt) etc. and is not relevant to the choice of reflections for refinement. *R*-factors based on F^2 are statistically about twice as large as those based on *F*, and *R*- factors based on ALL data will be even larger.

	x	У	Z		$U_{\rm iso}*/U_{\rm eq}$	
Si1	0.35065 (5)	0.48948 (1	0) 0.548	399 (8)	0.0361 (2)	
C1	0.26293 (17)	0.4896 (3)	0.657	72 (3)	0.0312 (5)	
C2	0.17225 (18)	0.4309 (3)	0.593	39 (3)	0.0341 (6)	
H2A	0.1533	0.3895	0.491	1	0.041*	
C3	0.10866 (17)	0.4313 (3)	0.676	58 (3)	0.0338 (6)	
H3A	0.0474	0.3906	0.629	99	0.041*	
C4	0.13394 (16)	0.4907 (3)	0.828	32 (3)	0.0288 (5)	
C5	0.22485 (18)	0.5474 (4)	0.893	35 (3)	0.0357 (6)	
H5A	0.2441	0.5869	0.996	58	0.043*	
C6	0.28736 (18)	0.5469 (4)	0.809	98 (3)	0.0365 (6)	
H6A	0.3487	0.5866	0.857	72	0.044*	
C7	0.4368 (2)	0.3127 (5)	0.620	03 (4)	0.0660 (11)	
H7A	0.4832	0.3164	0.565	51	0.099*	
H7B	0.4051	0.2006	0.602	28	0.099*	
H7C	0.4674	0.3283	0.730)5	0.099*	
C8	0.2933 (2)	0.4691 (4)	0.340	01 (3)	0.0468 (7)	
H8A	0.2475	0.5617	0.306	50	0.070*	
H8B	0.2624	0.3565	0.318	32	0.070*	
H8C	0.3398	0.4785	0.285	54	0.070*	
C9	0.06529 (16)	0.4952 (3)	0.916	66 (3)	0.0292 (5)	
C10	0.07421 (17)	0.6139 (3)	1.036	54 (3)	0.0319 (6)	
H10A	0.1249	0.6924	1.062	22	0.038*	
C11	0.01023 (17)	0.6186 (3)	1.117	79 (3)	0.0322 (6)	
H11A	0.0178	0.7004	1.198	35	0.039*	
H1	0.3948 (17)	0.649 (3)	0.578	3 (3)	0.036 (7)*	
Atomic disp	lacement parameters	$(Å^2)$				
	U^{11}	U^{22}	U^{33}	U^{12}	U^{13}	U^{23}
Si1	0.0341 (4)	0.0455 (5)	0.0312 (4)	-0.0040 (3)	0.0137 (3)	0.0030 (3)
C1	0.0319 (13)	0.0320 (13)	0.0314 (12)	0.0010 (11)	0.0119 (10)	0.0015 (11)

Fractional atomic coordinates and isotropic or equivalent isotropic displacement parameters (A^2)

supplementary materials

C2	0.0384 (14)	0.0381 (14)	0.0266 (12)	-0.0009 (12)	0.0113 (11)	-0.0023 (11)
C3	0.0295 (13)	0.0366 (14)	0.0345 (14)	-0.0019 (11)	0.0085 (11)	-0.0027 (11)
C4	0.0300 (12)	0.0265 (12)	0.0298 (12)	0.0007 (10)	0.0086 (9)	-0.0002 (10)
C5	0.0359 (14)	0.0432 (16)	0.0281 (13)	-0.0026 (12)	0.0100 (10)	-0.0044 (11)
C6	0.0308 (13)	0.0426 (15)	0.0364 (14)	-0.0037 (12)	0.0106 (11)	-0.0023 (12)
C7	0.0479 (19)	0.094 (3)	0.065 (2)	0.0250 (19)	0.0313 (17)	0.026 (2)
C8	0.0528 (18)	0.0535 (19)	0.0370 (15)	-0.0004 (15)	0.0178 (13)	-0.0022 (13)
C9	0.0294 (12)	0.0298 (13)	0.0280 (11)	0.0030 (11)	0.0079 (9)	0.0045 (10)
C10	0.0295 (12)	0.0337 (13)	0.0319 (13)	-0.0033 (11)	0.0082 (10)	-0.0032 (10)
C11	0.0351 (14)	0.0331 (14)	0.0287 (12)	-0.0025 (11)	0.0101 (11)	-0.0037 (10)

Geometric parameters (Å, °)

Si1—C8	1.848 (3)	C6—H6A	0.9500
Si1—C7	1.865 (3)	C7—H7A	0.9800
Si1—C1	1.879 (2)	С7—Н7В	0.9800
Si1—H1	1.39 (3)	C7—H7C	0.9800
C1—C2	1.395 (3)	C8—H8A	0.9800
C1—C6	1.401 (3)	C8—H8B	0.9800
C2—C3	1.393 (3)	C8—H8C	0.9800
C2—H2A	0.9500	C9—C11 ⁱ	1.401 (3)
C3—C4	1.396 (3)	C9—C10	1.402 (3)
С3—НЗА	0.9500	C10—C11	1.388 (3)
C4—C5	1.396 (3)	C10—H10A	0.9500
C4—C9	1.496 (3)	C11—C9 ⁱ	1.401 (3)
C5—C6	1.384 (3)	C11—H11A	0.9500
С5—Н5А	0.9500		
C8—Si1—C7	111.07 (16)	С1—С6—Н6А	119.0
C8—Si1—C1	110.83 (12)	Si1—C7—H7A	109.5
C7—Si1—C1	110.34 (13)	Si1—C7—H7B	109.5
C8—Si1—H1	108.8 (10)	H7A—C7—H7B	109.5
C7—Si1—H1	109.7 (10)	Si1—C7—H7C	109.5
C1—Si1—H1	106.0 (10)	H7A—C7—H7C	109.5
C2-C1-C6	116.6 (2)	H7B—C7—H7C	109.5
C2-C1-Si1	123.04 (18)	Si1—C8—H8A	109.5
C6-C1-Si1	120.39 (19)	Si1—C8—H8B	109.5
C3—C2—C1	122.0 (2)	H8A—C8—H8B	109.5
С3—С2—Н2А	119.0	Si1—C8—H8C	109.5
C1—C2—H2A	119.0	H8A—C8—H8C	109.5
C2—C3—C4	120.7 (2)	H8B—C8—H8C	109.5
С2—С3—НЗА	119.7	C11 ⁱ —C9—C10	117.8 (2)
С4—С3—Н3А	119.7	C11 ⁱ —C9—C4	121.1 (2)
C5—C4—C3	117.8 (2)	C10—C9—C4	121.1 (2)
С5—С4—С9	121.3 (2)	C11—C10—C9	121.1 (2)
C3—C4—C9	120.9 (2)	C11—C10—H10A	119.5
C6—C5—C4	121.0 (2)	C9—C10—H10A	119.5
С6—С5—Н5А	119.5	C10—C11—C9 ⁱ	121.1 (2)
C4—C5—H5A	119.5	C10-C11-H11A	119.4

C5—C6—C1	122.0 (2)	C9 ⁱ —C11—H11A	119.4
С5—С6—Н6А	119.0		
C8—Si1—C1—C2	17.6 (3)	C4—C5—C6—C1	-0.2 (4)
C7—Si1—C1—C2	-105.9 (3)	C2-C1-C6-C5	-0.7 (4)
C8—Si1—C1—C6	-163.7 (2)	Si1—C1—C6—C5	-179.4 (2)
C7—Si1—C1—C6	72.8 (3)	C5—C4—C9—C11 ⁱ	-154.1 (2)
C6—C1—C2—C3	0.8 (4)	C3—C4—C9—C11 ⁱ	26.7 (4)
Si1—C1—C2—C3	179.6 (2)	C5-C4-C9-C10	26.2 (4)
C1—C2—C3—C4	-0.2 (4)	C3—C4—C9—C10	-153.1 (2)
C2—C3—C4—C5	-0.7 (4)	C11 ⁱ —C9—C10—C11	-0.1 (4)
C2—C3—C4—C9	178.6 (2)	C4—C9—C10—C11	179.7 (2)
C3—C4—C5—C6	0.9 (4)	C9—C10—C11—C9 ⁱ	0.1 (4)
C9—C4—C5—C6	-178.4 (2)		
Symmetry codes: (i) $-x$, $-y+1$, $-z+2$.			

Hydrogen-bond geometry (Å, °)

Cg1 is the centroid of the C1–C6 ring.					
D—H···A	<i>D</i> —Н	$H \cdots A$	$D \cdots A$	D—H··· A	
C8—H8b····Cg1 ⁱⁱ	0.98	2.86	3.826 (3)	171	
C10—H10a…Cg1 ⁱⁱⁱ	0.95	2.98	3.788 (3)	143	
Symmetry codes: (ii) $x, -y+1/2, z-1/2$; (iii) $x, -y+3/2, z+1/2$.					





